10/568951

IAP20 Reside COTATO 22 FEB 2006

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

T			1.	
In	re	ann	licati	on of
***		wpp	11044	011 01

Taku HIRAYAMA et al.

Mail Stop: PCT

Serial No. NEW

Attorney Docket No. 2006-0227A

Filed February 22, 2006

MATERIAL FOR FORMING RESIST PROTECTIVE FILM FOR LIQUID IMMERSION LITHOGRAPHY PROCESS, RESIST PROTECTIVE FILM FORMED BY THE MATERIAL, AND METHOD OF FORMING RESIST PATTERNS USING THE MATERIAL [Corresponding to PCT/JP2004/012204 Filed August 25, 2004]

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

la.

Pursuant to the provisions of 37 CFR 1.56, 1.97 and 1.98, Applicants request consideration of the references listed on attached form PTO-1449 and any additional information identified below in paragraph 3. A legible copy of each reference listed on the Form PTO-1449 is enclosed, except a copy is not provided for:

[X]	each U.S. Patent and U.S. Patent application publication;
0	each reference previously cited in the international application PCT/; and/or
	each reference previously cited in prior parent application Serial No.
	·
(X) TI	his Information Disclosure Statement is submitted:

within three months of the filing date (or of entry into the National Stage) of the above-entitled application, or

before the mailing of a first Office Action on the merits or the mailing of a first Office Action after the filing of an RCE,

and thus no certification and/or fee is required.

1b. [] This Information Disclosure Statement is submitted

after the events of above paragraph 1a and prior to the mailing date of a final Office Action or a Notice of Allowance or an action which otherwise closes prosecution in the application, and thus:

- (1) [] the certification of paragraph 2 below is provided, or
- (2) [] the fee of \$180.00 specified in 37 CFR 1.17(p) is enclosed.
- 1c. [] This Information Disclosure Statement is submitted:

after the mailing date of a final Office Action or Notice of Allowance or action which otherwise closes prosecution in the application, and prior to payment of the issue fee, and thus:

the certification of paragraph 2 below is provided, and

the fee of \$180.00 specified in 37 CFR 1.17(p) is enclosed.

- 2. It is hereby certified
 - a. [] that each item of information contained in this Information Disclosure
 Statement was first cited in any communication from a foreign patent office in a
 counterpart foreign application not more than three months prior to the filing of
 the Statement, or
 - b. [] that no item of information contained in the Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart foreign application and, to the knowledge of the person signing the certification after making reasonable inquiry, was known to any individual designated in §1.56(c) more than three months prior to the filing of the Statement.

1AP20 Res'd POTFTO 22 FEB 2006

- Consideration of the following list of additional information (including any copending or 3. [] abandoned U.S. application, prior uses and/or sales, etc.) is requested.
- 4. For each non-English language reference listed on the attached form PTO-1449, reference is made to:
 - a full or partial English language translation submitted herewith, a. []
 - b. [X] a foreign patent office search report (in the English language) submitted herewith,
 - c. [] the concise explanation contained in the specification of the present application at page,
 - d. [X] the concise explanation set forth in the attached English language abstract,
 - e. [X] the concise explanation set forth below or on a separate sheet attached to the reference:

US 2003/0129534 corresponds to JP 2003-167352 US 5,631,314 & US 5,783,362 corresponds to JP 8-15859 US 2002/0161148 corresponds to JP 2002-234916 US 2002/0177067 corresponds to JP 2002-338634 EP 1 365 290 A1 corresponds to WO 02/065212 US 2003/0219682 corresponds to JP 2003-345026

5. [X] A foreign patent office search report citing one or more of the references is enclosed.

Respectfully submitted,

FEES FOR 1 LD CONTROL DEP ACCOUNT NO. 25-0575

Taku HIRAYAMA et al.

By Matthew M. Jacob

Registration No. 25,154

Attorney for Applicants

MJ/krg Washington, D.C. 20006-1021 Telephone (202) 721-8200 Facsimile (202) 721-8250 February 22, 2006

Sheet 1 of 2 INFORMATION DISCLOSURE STATEMENT											
FORM PTO 1449 (modified)				ATTY DOCK 2006-022			SERIAL I	20/50	38951		
U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S)				APPLICANT AP20 ROS O POTATO 22 FEB 2006							
(Use several sheets if necessary) Date Submitted to PTO: February 22, 2006				FILING DATE February 22, 2006				GROUP			
7	S. PATENT DOCUMENTS										
*EXAMINER INITIAL		DOCUMENT DATE NUMBER			IAME	CLA	\ss	SUBCLASS	S FILING DATE IF APPROPRIATE		
	АА	2003/0129534	7/2003	Yamaz	zaki et al.						
	АВ	5,631,314	5/1997	Waki	ya et al.						
	AC	5,783,362	7/1998	Waki	ya et al.						
	AD	2002/0161148	10/2002	Hara	da et al.			-			
···	AE	2002/0177067	11/2002	•	Kim	·					
	1 1		FORE	IGN PATENT D	OCUMENTS						
		DOCUMENT NUMBER	DATE	COI	DUNTRY CLASS			SUBCLASS	TRANSLATION YES NO		
	AF	2003-167352	6/2003		JP						
	AG	8-15859	1/1996		JP						
	АН	2001-133984	5/2001		JP				abstract		
	Al	8-95253	4/1996		JP	<u> </u>			abstract		
	AJ	7-234514	9/1995		JP	a			abstract		
	AK	10-69091	3/1998		JP				abstract		
	AL	2000-275835	10/2000		JP				abstract		
	АМ	10-120968	5/1998	,	JP				abstract		
	AN	99/49504	9/1999	V	wo				abstract		
	AO	62-65326	3/1987		JP				abstract		
,	AP	2002-234916	8/2002		JP						
	AQ	2002-145962	5/2002		JP				abstract		
***	AR	2002-338634	11/2002		JP						
OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)											
	AS										
EXAMINER				DATE CONSIDERED							
					DATE CONSIDERED						

IAP20 Reconding 2 2 FEB 2006

Sheet 2 of 2 INFORMATION DISCLOSURE STATEMENT											
FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S)				ATTY DOCKET NO. SERIAL NEW			. NO. 10/5 68951				
				APPLICANT Taku HIRAYAMA et al.							
(Use several sheets if necessary) Date Submitted to PTO: February 22, 2006				FILING DATE GROUP February 22, 2006							
			U.	S. PATENT DO	OCUMENTS		-				
*EXAMINER INITIAL		DOCUMENT NUMBER	DATE		NAME	С	CLASS SUBCLASS		FILING DATE IF APPROPRIATE		
	AA	2003/0219682	11/2003	Wa	kiya et al.						
	АВ										
	AC										
	AD										
	AE										
	AF										
	AG										
			FORI	EIGN PATENT	DOCUMENTS	•		•			
		DOCUMENT NUMBER	DOCUMENT DATE COUNTRY CLASS SUBCLASS TRAN						TRANSLA YES		
	АН	1 365 290 A1	11/2003		EP						
	AI	02/065212	8/2002		wo				abstract		
	AJ	2003-345026	12/2003		JP						
	AK	2004/088429	10/2004		wo		·		abstract		
	AL	2004/079800	9/2004		wo				abstract		
	AM	2004/074937	9/2004		wo				abstract		
	AN	2004/068242	8/2004		wo				abstract		
	OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)										
	AO	J. A. Hoffnagle et al., "Liquid immersion deep-ultraviolet interferometric lithography", Journal of Vacuum Science & Technology B17(6), Nov/Dec 1999, pgs. 3306-3309.									
	AP	M. Switkes et al., "Immersion lithography at 157 nm", Journal of Vacuum Science & Technology B19(6), Nov/Dec 2001, pgs. 2353-2356.									
	AQ	M. Switkes et al., "Resolution Enhancement of 157 nm Lithography by Liquid Immersion", Proceedings of SPIE Vol. 4691, 2002, pgs. 459-465.									
EXAMINER				DATE CONSIDERED							